



US00D919188S

(12) **United States Design Patent** (10) **Patent No.:** **US D919,188 S**
Sun (45) **Date of Patent:** **** May 11, 2021**

(54) **PROTECTIVE MASK**

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* cited by examiner

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(**) Term: **15 Years**

(57) **CLAIM**

(21) Appl. No.: **29/690,718**

I claim the ornamental design for the protective mask, as shown and described.

(22) Filed: **May 10, 2019**

(30) **Foreign Application Priority Data**

DESCRIPTION

Jan. 24, 2019 (CN) 201930040902.1
Apr. 30, 2019 (CN) 201930207907.9

(51) **LOC (13) Cl.** **29-02**

(52) **U.S. Cl.**
USPC **D29/110**

(58) **Field of Classification Search**
USPC D29/122, 109–112
CPC A61F 9/06
See application file for complete search history.

FIG. 1 is an upper prospective view of a protective mask my new design;
FIG. 2 is another upper prospective view thereof;
FIG. 3 is a front elevational view thereof;
FIG. 4 is a rear elevational view thereof;
FIG. 5 is a left side elevational view thereof;
FIG. 6 is a right side elevational view thereof;
FIG. 7 is a top plan view thereof; and,
FIG. 8 is a bottom plan view thereof.

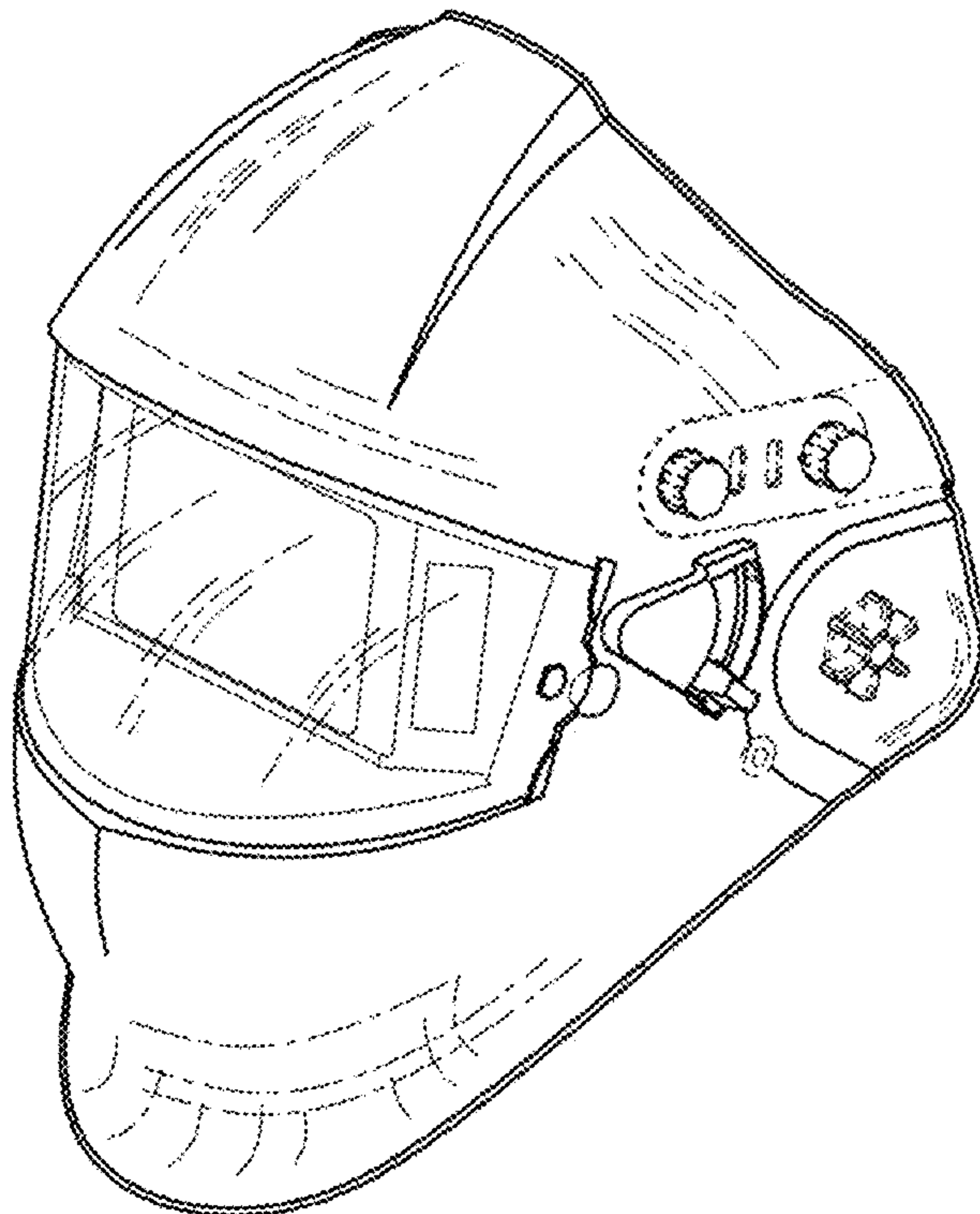
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The broken lines in the Figures show portions of the protective mask which form no part of the claimed design.

1 Claim, 8 Drawing Sheets



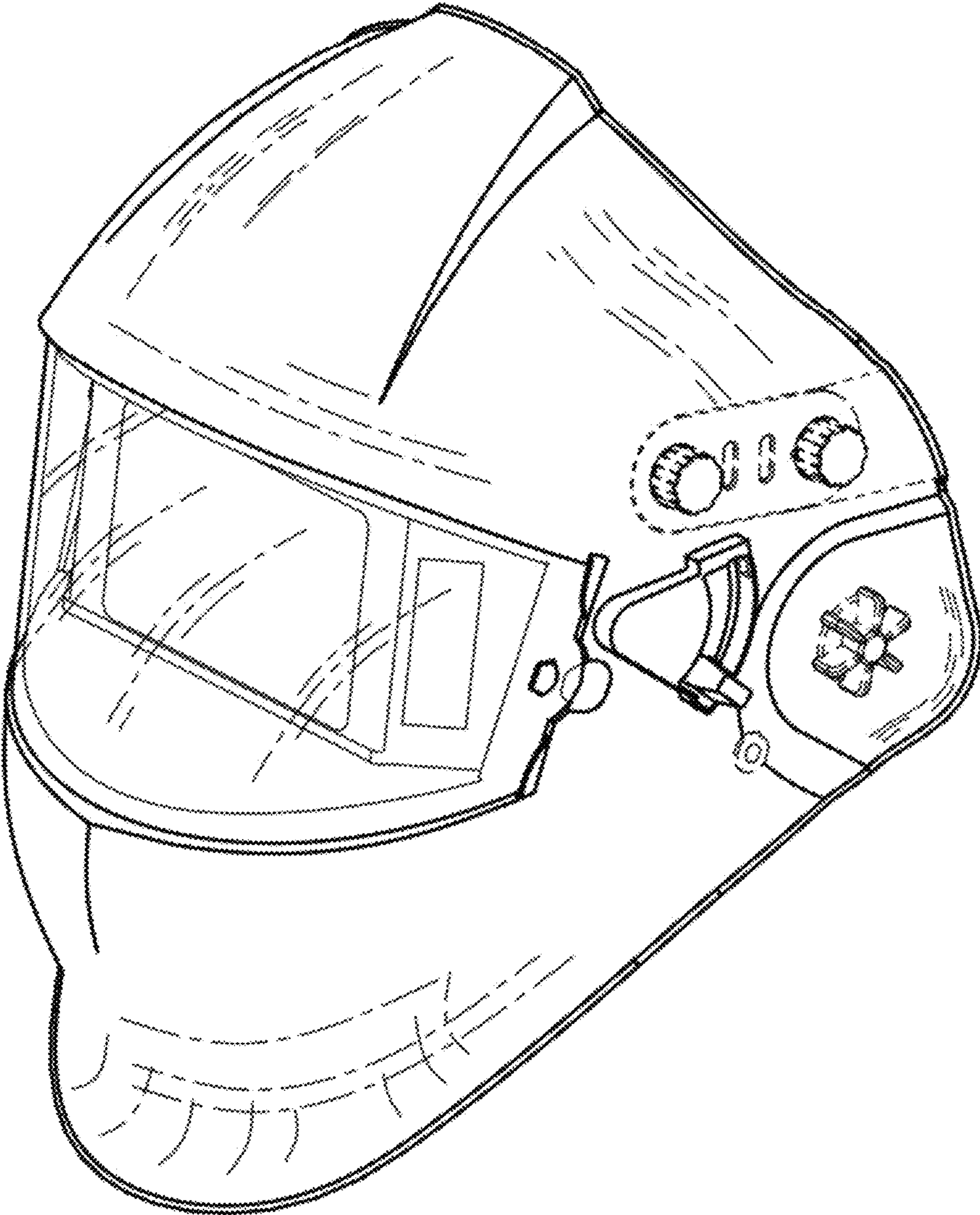


FIG. 1

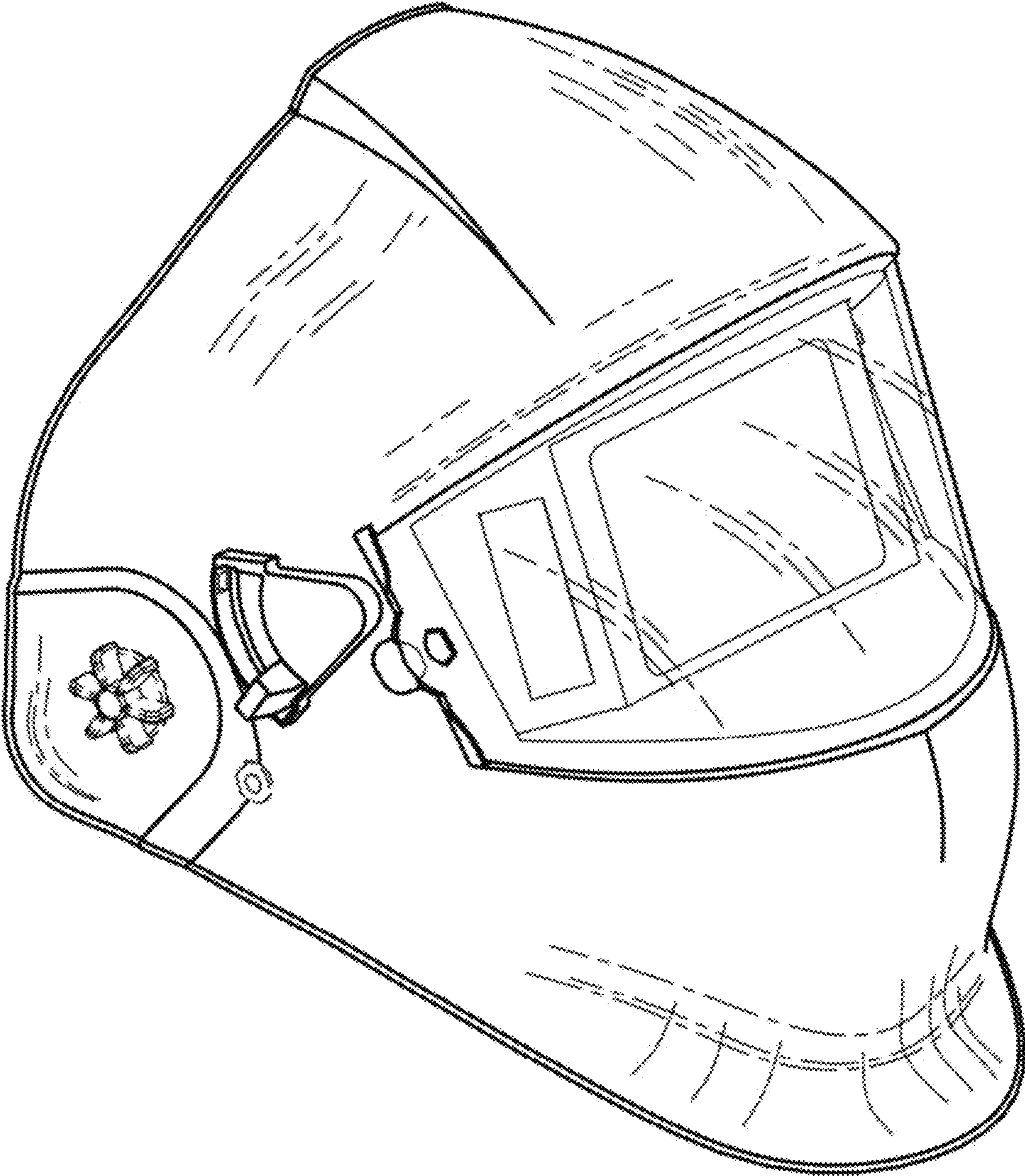


FIG. 2

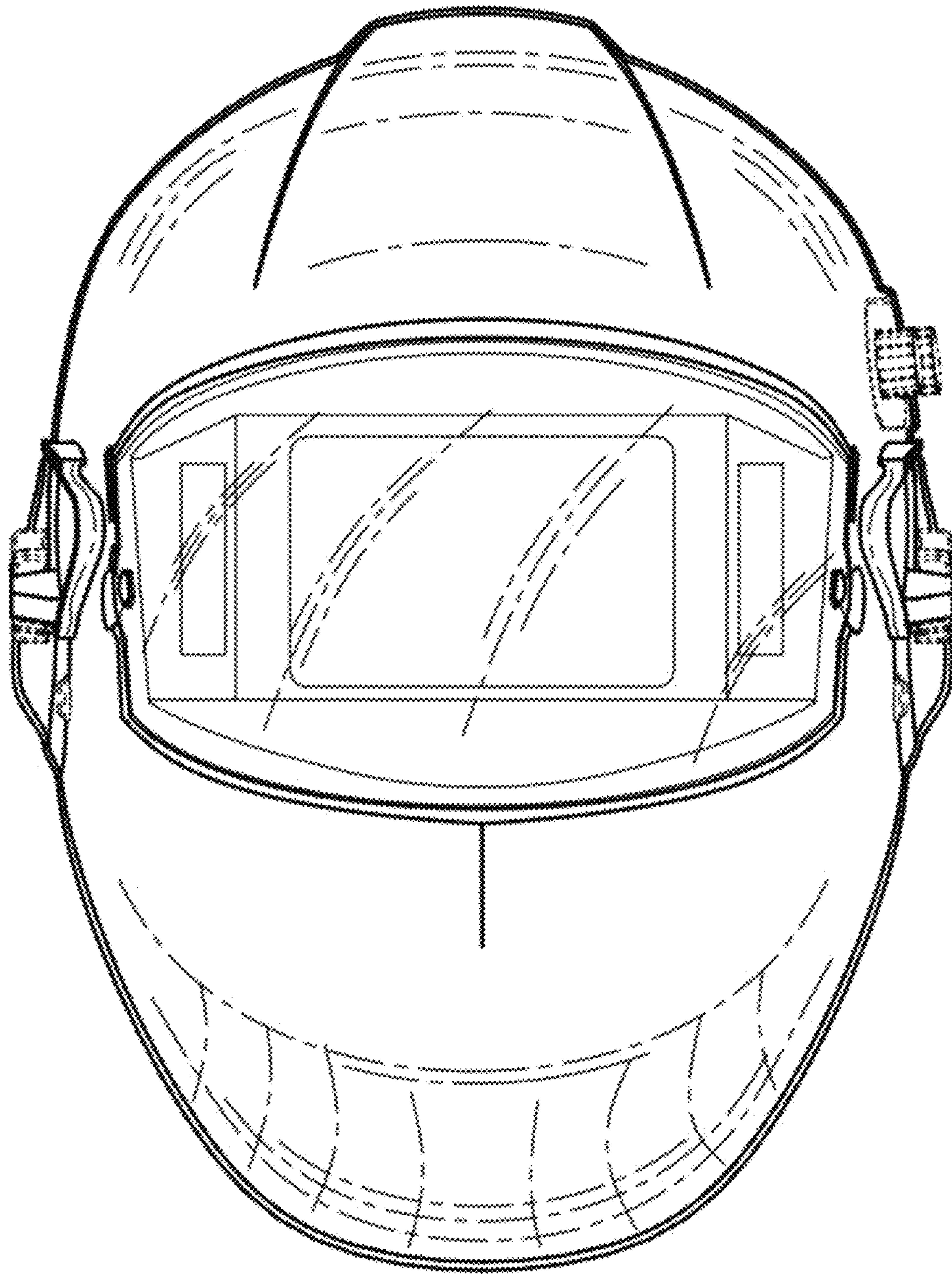


FIG. 3

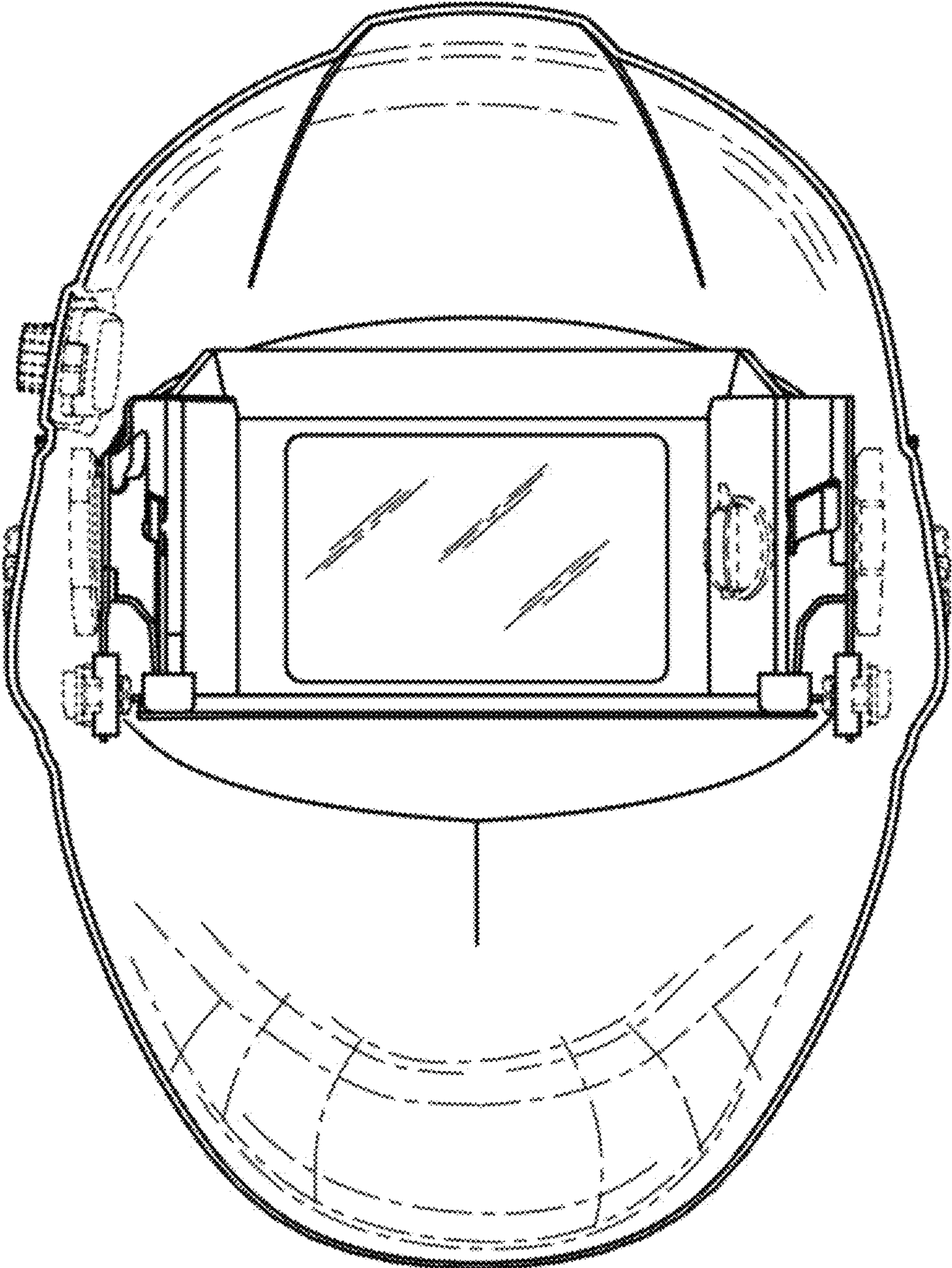


FIG. 4

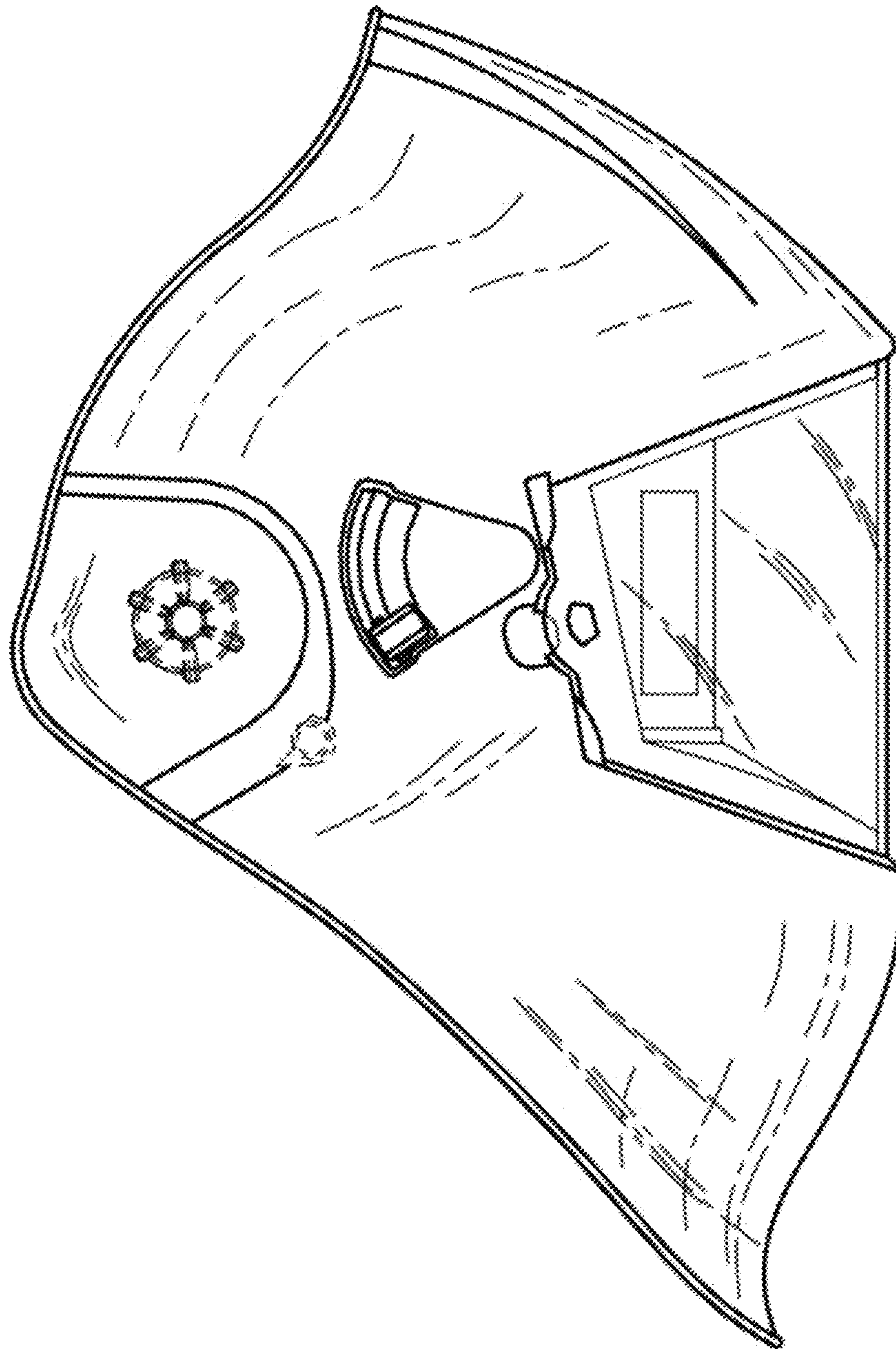


FIG. 5

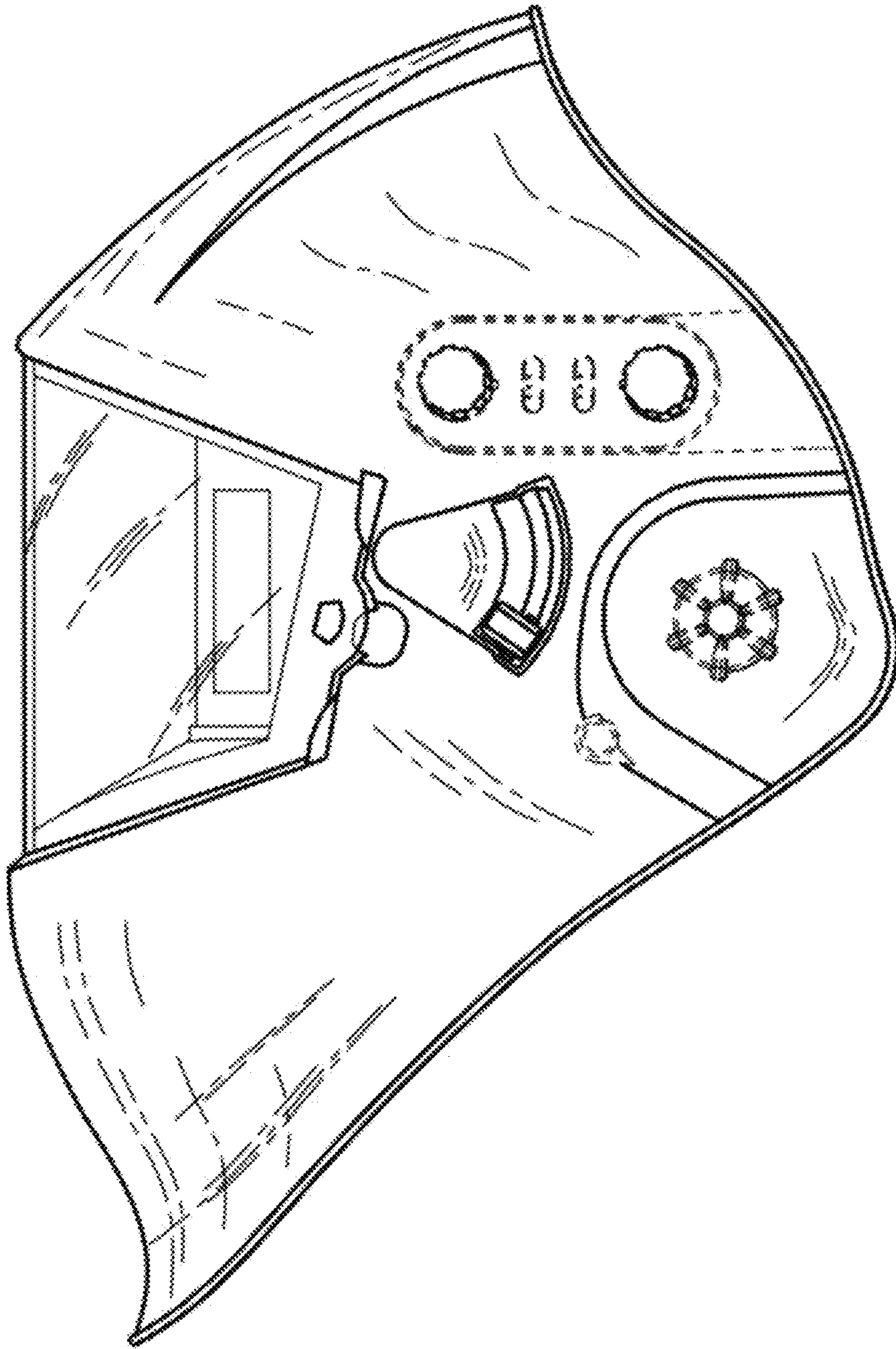


FIG. 6

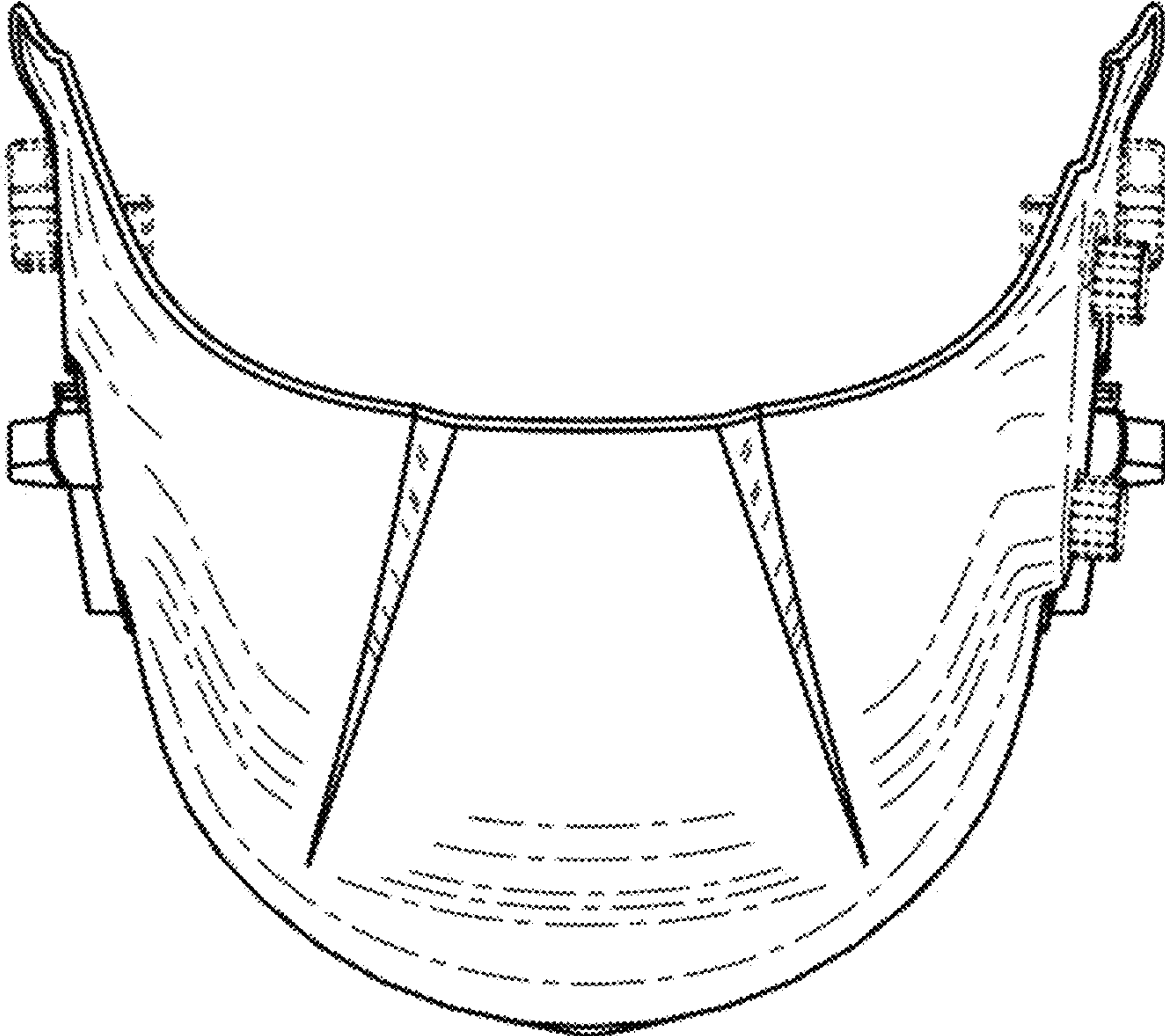


FIG. 7

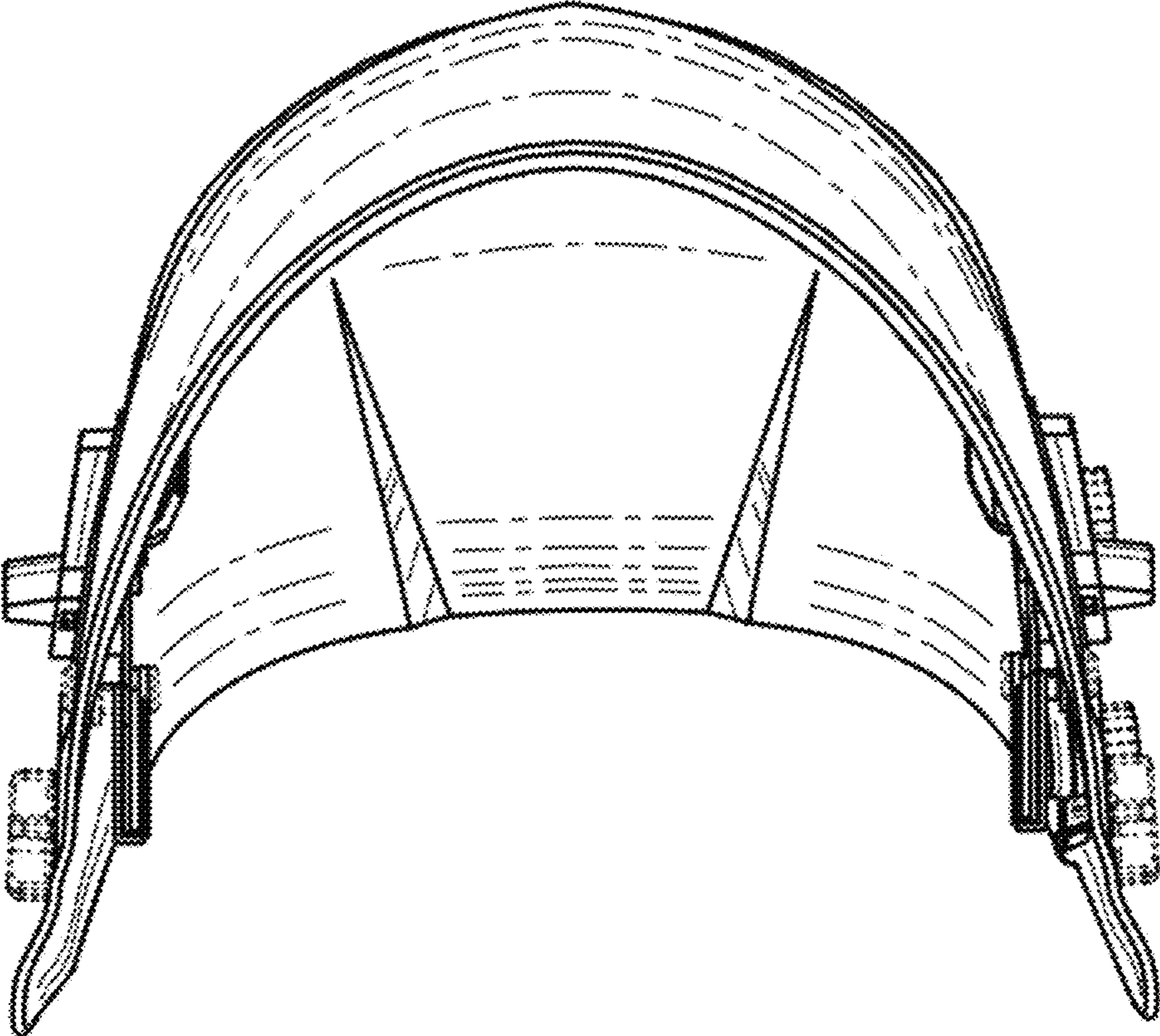


FIG. 8